



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.: 10/780,929

Confirmation Number: 1902

Applicant: Douglas James Tweet *et al.*

Filed: February 17, 2004

Group #: 2818

Examiner: Chuong A. Luu

Docket No: SLA.0735

Customer No: 55376

For: Low Temperature Anneal to Reduce Defects in Hydrogen-Implanted, Relaxed SiGe

MS AMENDMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, Virginia 22313-1450

RESPONSE TO OFFICE ACTION UNDER 37 C.F.R. § 1.111

Change of Correspondence Address

Introductory Comments

In response to the Office Action dated July 13, 2005, please amend the above-identified Application as follows:

Amendment to the Specification None

Amendment to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Amendment to the Drawings None

Remarks/Arguments begin on page 7 of this paper.

An **Appendix** is not included.